

L Number	Hits	Search Text	DB	Time stamp
-	12	((("4239661") or ("4958061") or ("5286678") or ("5288651") or ("5290361") or ("5447568") or ("5466389") or ("5783495") or ("5972862") or ("5855811") or ("5679171") or ("6096650")).PN.	USPAT; US-PGPUB	2001/11/10 22:53
-	4847	ammonium adj fluoride	USPAT; US-PGPUB	2001/11/08 16:30
-	99	(ammonium adj fluoride) with cleaning	USPAT; US-PGPUB	2001/11/10 21:57
-	58	tetra\$lalkyl adj ammonium adj fluoride	USPAT; US-PGPUB	2001/11/08 15:28
-	1	("5780406").PN.	USPAT; US-PGPUB	2001/11/08 15:28
-	175	sheet\$1by\$1sheet	USPAT; US-PGPUB	2001/11/08 15:35
-	30	sheet\$1by\$1sheet and semiconductor	USPAT; US-PGPUB	2001/11/08 15:36
-	14	(sheet\$1by\$1sheet and semiconductor) and cleaning	USPAT; US-PGPUB	2001/11/08 15:36
-	1	("5402807").PN.	USPAT; US-PGPUB	2001/11/08 16:30
-	91	(ammonium adj fluoride) with peroxide	USPAT; US-PGPUB	2001/11/08 16:31
-	86	((ammonium adj fluoride) with peroxide) with (hydrogen adj peroxide)	USPAT; US-PGPUB	2001/11/08 16:31
-	72	((ammonium adj fluoride) with peroxide) with (hydrogen adj peroxide)) and semiconductor	USPAT; US-PGPUB	2001/11/08 16:32
-	15	((ammonium adj fluoride) with peroxide) with (hydrogen adj peroxide)) and semiconductor) and (cleaning near wafer)	USPAT; US-PGPUB	2001/11/08 16:32
-	404	("438/745").CCLS.	USPAT; US-PGPUB	2001/11/08 17:46
-	205	("438/689").CCLS.	USPAT; US-PGPUB	2001/11/08 17:51
-	221	("438/704").CCLS.	USPAT; US-PGPUB	2001/11/08 17:57
-	367	("134/1.3").CCLS.	USPAT; US-PGPUB	2001/11/08 18:12
-	761	("252/79.1").CCLS.	USPAT; US-PGPUB	2001/11/08 18:13
-	323	("252/79.5").CCLS.	USPAT; US-PGPUB	2001/11/10 19:29
-	1	("5135608").PN.	USPAT; US-PGPUB	2001/11/08 18:25
-	323	("252/79.5").CCLS.	USPAT; US-PGPUB	2001/11/10 19:38
-	761	("252/79.1").CCLS.	USPAT; US-PGPUB	2001/11/10 19:57
-	356	("510/175").CCLS.	USPAT; US-PGPUB	2001/11/10 19:58
-	60	("438/908").CCLS.	USPAT; US-PGPUB	2001/11/10 22:55
-	89	("438/907").CCLS.	USPAT; US-PGPUB	2001/11/10 20:34
-	75	((("438/907").CCLS.) not ("438/908").CCLS.)	USPAT; US-PGPUB	2001/11/10 20:34
-	1	("5277835").PN.	DERWENT	2001/11/10 21:19
-	2	(U11-A09 and U11-C04A1 and U11-C07B and U11-C07C3).epi.	DERWENT	2001/11/10 21:21
-	3142	L04-C07C.cpi.	DERWENT	2001/11/10 21:21
-	208	L04-C07C.cpi. and ammonium	DERWENT	2001/11/10 21:21
-	96	(L04-C07C.cpi. and ammonium) and fluoride	DERWENT	2001/11/10 21:21
-	92	(L04-C07C.cpi. and ammonium) and (ammonium near fluoride)	DERWENT	2001/11/10 21:21

-	13	((L04-C07C.cpi. and ammonium) and (ammonium near fluoride)) and clean\$6	DERWENT	2001/11/10 21:31
-	1	(B05D001/00 and C09K013/08 and C23F001/24 and H01L021/306 and H01L021/308 and H01L021/31 and H01L021/311).ipc.	EPO; JPO; DERWENT	2001/11/10 21:32
-	1	(B05D001/00 and C09K013/08 and C23F001/24 and H01L021\$).ipc.	EPO; JPO; DERWENT	2001/11/10 21:33
-	1	(B05D001\$ and C09K013/08 and C23F001/24 and H01L021\$).ipc.	EPO; JPO; DERWENT	2001/11/10 21:33
-	1	(B05D\$\$ and C09K013/08 and C23F001/24 and H01L021\$).ipc.	EPO; JPO; DERWENT	2001/11/10 21:33
-	3	(B05D\$\$ and C23F001/24 and H01L021\$).ipc.	EPO; JPO; DERWENT	2001/11/10 21:34
-	169	(ammonium adj fluoride) and clean\$6	EPO; JPO; DERWENT	2001/11/10 21:35
-	17	((ammonium adj fluoride) and clean\$6) and peroxide	EPO; JPO; DERWENT	2001/11/10 21:35
-	1	("5277835").PN.	USPAT; US-PGPUB	2001/11/10 21:53
-	16	((ammonium adj fluoride) with cleaning) and ultrasonic	USPAT; US-PGPUB	2001/11/10 21:58
-	1	5135608.pn.	USPAT; US-PGPUB	2001/11/10 22:53
-	6	multi\$1chamber and sheet\$1by\$1sheet	USPAT; US-PGPUB	2001/11/10 22:57
-	942	multi\$1chamber and continuous	USPAT; US-PGPUB	2001/11/10 22:58
-	129	(multi\$1chamber and continuous ) and (continuous near process\$6)	USPAT; US-PGPUB	2001/11/10 22:59
-	254	(clean\$5 near wafer) with oxide	USPAT; US-PGPUB	2001/11/13 08:35
-	7	((clean\$5 near wafer) with oxide) with peroxide	USPAT; US-PGPUB	2001/11/13 08:36
-	378	((silicon adj oxide) with etch\$6) and (ammonium adj fluoride)	USPAT; US-PGPUB	2001/11/13 08:43
-	292	((silicon adj oxide) with etch\$6) and (ammonium adj fluoride) and (etch\$6 with (ammonium adj fluoride))	USPAT; US-PGPUB	2001/11/13 08:44
-	48	((silicon adj oxide) with etch\$6) and (ammonium adj fluoride) and (etch\$6 with (ammonium adj fluoride)) and (hydrogen adj peroxide)	USPAT; US-PGPUB	2001/11/13 08:48
-	86	(ammonium adj fluoride) with (hydrogen adj peroxide)	USPAT; US-PGPUB	2001/11/13 08:49
-	55	((("3876468") or ("3911169") or ("4087367") or ("4171242") or ("4329435") or ("4381341") or ("4845050") or ("4876042") or ("4962063") or ("5043299") or ("5089084") or ("5135608") or ("5158616") or ("5178682") or ("5229323") or ("5268069") or ("5277835") or ("5296093") or ("5320709") or ("5360748") or ("5374581") or ("5376223") or ("5380682") or ("5402807") or ("5412240") or ("5413664") or ("5454901") or ("5478436") or ("5478780") or ("5494494") or ("5496485") or ("5498293") or ("5503173") or ("5512320") or ("5530266") or ("5578520") or ("5630904") or ("5679171") or ("5716495") or ("5716535") or ("5779520") or ("5780406") or ("5803956") or ("5858106") or ("5858863") or ("5968848") or ("5972123") or ("5990060") or ("6030932") or ("6068788") or ("6117350") or ("6145519") or ("6224785") or ("6284721") or ("6294027")).PN.	USPAT; US-PGPUB	2001/11/13 09:37
-	1	((tetra\$1alkyl adj ammonium adj fluoride) TMAF) with (hydrogen adj peroxide)	USPAT; US-PGPUB	2001/11/13 09:39